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Applicant(s): Akibiko OTOGURO, et al.		
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U.S. PATENT DOCUMENTS

Examiner Initial	Document No.	Name	Date	Class	Subclass	Filing Date (If appropriate)
	AA					
	AB					
	AC					
	AD					

FOREIGN PATENT DOCUMENTS

	Document No.	Date	Country	Translation (Yes or No)
CK	AE	4-5658	01/09/92	Japan Yes-Abstract/Discussed in the specification
CK	AF	60-254034	12/14/85	Japan Yes-Abstract/Discussed in the specification
CK	AG	5-265224	10/15/93	Japan Yes-Abstract/Discussed in the specification
	AH			
	AI			

OTHER DOCUMENTS

CK	AJ	J.M. Moran et al.; "High resolution, steep profile resist patterns"; <i>Journal of Vacuum Science Technology</i> ; Vol. 16; No. 6; November/December 1979; pp. 1620-1624./Discussed in the specification.
	AK	

Examiner *Christy Faracek* Date Considered 7/8/04